1. Introduction

It is now well established that the reduction/exfoliation of graphite oxide by certain methods can result in the production of few-layer graphene (FLG) like structures, which are defective by nature. Hydrogen exfoliated graphene (HEG) is an interesting class of few-layer graphene, which is synthesized via hydrogen induced simultaneous exfoliation-reduction of graphite oxide. HEG exhibits strong optical limiting (OL) due to defect states arising from a large number of structural defects as well as oxygen functionalities present on its surface. Recently, we have shown that OL in HEG can be improved by simple acid functionalization, as it results in an increased number of defects. In the present study, we demonstrate that the OL performance of functionalized HEG (f-HEG) can be further improved, in both the short-pulse (nanosecond) and ultrafast (femtosecond) laser excitation regimes, using hybrids of f-HEG with transition metal oxide nanoparticles (NPs) such as CuO. The enhancement in the OL efficiency of the hybrid arises from strong nonlinear absorption in CuO NPs, which is determined mostly by interband and intraband transitions. The presence of defect states in the samples is confirmed using ultrafast pump–probe measurements, which reveal a delayed carrier relaxation due to carrier trapping by these states. Furthermore, we show that the occurrence of induced thermal scattering is minimal in these water dispersed systems, such that OL occurs predominantly due to nonlinear absorption.

Enhanced optical limiting and carrier dynamics in metal oxide-hydrogen exfoliated graphene hybrids

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Hydrogen exfoliated graphene (HEG) is an interesting class of few-layer graphene, which is synthesized via hydrogen induced simultaneous exfoliation-reduction of graphite oxide. HEG exhibits strong optical limiting (OL) due to defect states arising from a large number of structural defects as well as oxygen functionalities present on its surface. Recently, we have shown that OL in HEG can be improved by simple acid functionalization, as it results in an increased number of defects. In the present study, we demonstrate that the OL performance of functionalized HEG (f-HEG) can be further improved, in both the short-pulse (nanosecond) and ultrafast (femtosecond) laser excitation regimes, using hybrids of f-HEG with transition metal oxide nanoparticles (NPs) such as CuO. The enhancement in the OL efficiency of the hybrid arises from strong nonlinear absorption in CuO NPs, which is determined mostly by interband and intraband transitions. The presence of defect states in the samples is confirmed using ultrafast pump–probe measurements, which reveal a delayed carrier relaxation due to carrier trapping by these states. Furthermore, we show that the occurrence of induced thermal scattering is minimal in these water dispersed systems, such that OL occurs predominantly due to nonlinear absorption.
performance. It is expected that the electronic, thermal and optical properties of HEG can be tuned by interfacing it with electron-rich TMO NPs. Moreover, these NPs prevent the restacking of individual HEG sheets and increase the surface area, thereby improving the performance of the hybrids in practical applications. In fact, it was recently shown that ZnO decoration enhances OL in the case of reduced graphene oxide. 9

Among the various TMOs, CuO NPs are of particular interest due to their excellent electronic, 10,11 electrochemical 12 and third order nonlinear optical 13 properties, which have received tremendous technological attention. The physicochemical properties of CuO such as the photoconductivity and the photochemistry can be tailored for fabricating optical switches and solar cells. Composites of CuO NPs with f-HEG have previously been studied by Baby et al. for field emission and transport properties. 5,13 The thermal conductivity of f-HEG is improved significantly with metal oxide decoration, making these composites suitable for coolant applications. 5 It is observed that decoration with CuO reduces the work function of f-HEG composite and increases its surface roughness, thus enhancing field emission. 2 In the present paper, we report the third order NLO properties of f-HEG–CuO NP hybrid (CuO/f-HEG) dispersed in water. We demonstrate that decoration with CuO NPs enhances NLA in f-HEG, yielding more efficient optical limiters. Moreover, we attempt to correlate various important factors such as defects in HEG, absorption characteristics of CuO NPs, interaction between f-HEG and NPs, and electron dynamics in the hybrid, to the observed enhancement in OL.

2. Experimental methods

2.1. Material synthesis

HEG is synthesized by the hydrogen induced simultaneous exfoliation-reduction of graphite oxide, as explained elsewhere. 1 The as-synthesized HEG is treated with concentrated sulphuric acid and nitric acid (3 : 1 by vol.) to obtain f-HEG. CuO/f-HEG hybrid is synthesized as follows. 200 mg of copper chloride is added to 20 ml of de-ionized (DI) water and sonicated for 5 min. The dispersion is then added to 200 mg of f-HEG dispersed in 20 ml of DI water, which is again sonicated for 30 min. The colloidal solution is then stirred for 24 h, during which copper is reduced from CuCl2 using a reducing solution, which is a mixture of 1 M NaBH4 and 0.1 M NaOH. Once the reduction reaction is over, the colloidal solution is washed with DI water and filtered using a cellulose membrane filter. The material thus obtained is further dried at 70 °C under vacuum for 6 h, and the final product is annealed at 350 °C for 2 h.

2.2. Characterization techniques

Powder X-ray diffraction studies were carried out using X’Pert PRO, PANalytical diffractometer with nickel-filtered Cu Kα radiation as the X-ray source. The sample was scanned in steps of 0.016° in the 2θ range of 10–90°. Raman spectra were obtained with a WITEC alpha 300 Confocal Raman system equipped with an Nd:YAG laser (532 nm) as the excitation source. Transmission electron microscopy studies were carried out using a TECNAI F-20 (S-TWIN) instrument. For TEM measurement, the powder samples were dispersed in absolute ethanol using mild ultrasonication and casted onto carbon coated Cu grid (SPI supplies, 200 mesh).

2.3. NLO measurements

The open aperture Z-scan technique was employed to study the NLO characteristics of the f-HEG–metal oxide hybrid. Excitation was by linearly polarized laser pulses of 5 ns duration at 532 nm, and 100 fs duration at 800 nm, respectively. Successive laser pulses excited the samples at a repetition rate of less than 0.5 Hz. From repeated knife edge measurements, the beam waist at the focus was calculated to be ~20 μm for the ns pulses and ~16 μm for the fs pulses. For nonlinear transmission measurements, the samples, which were uniformly dispersed in water, were taken into 1 mm thick quartz cuvettes. Appropriate concentrations were used such that the linear transmittance of the dispersions is the same (70%) at both excitation wavelengths. A detailed description of our Z-scan set up can be found in ref. 12.

2.4. Ultrafast pump–probe measurements

The experimental setup used for time resolved differential transmission measurements is detailed elsewhere. 23 Briefly, ultrafast laser pulses of ~70 fs duration at 580 nm were used for pumping as well as probing. These were derived from an optical parametric amplifier (TOPAS-C, Light Conversion) working at a repetition rate of 1 kHz, which was pumped by a Ti:sapphire regenerative amplifier. For maximum overlap, the pump and probe diameters were maintained at ~3 mm and ~1 mm, respectively, and the angle between them was reduced to ~3°. The energy ratio of pump and probe beams was maintained at 10 : 1 with the probe power being 0.5 mW. The pump and probe beams were focused onto the sample solution kept in a 5 mm thick cuvette using converging lenses of 20 cm and 15 cm focal lengths, respectively. The pump beam was modulated at 109 Hz using a mechanical chopper. Intensity of the transmitted probe was measured as a function of time delay between the pump and probe pulses using a Si-PIN diode with lock-in detection. Polarizations of the pump and probe beams were kept perpendicular to each other to prevent scattered pump light from reaching the detector.

3. Results and discussion

3.1. Material characterization

Powder X-ray diffraction patterns of f-HEG and CuO/f-HEG are shown in Fig. 1a. f-HEG has its characteristic (002) peak centered at 25°. The shift from the traditional sharp and intense graphitic peak at 26.5° suggests the absence of severe stacking along the c-axis, and a reduction in the crystallite size. Graphite typically contains about 100–200 layers along the c-axis, whereas after exfoliation, the sample contains only 5–10 layers. Moreover, while the graphite used here has a flake size of 45 μm, the HEG obtained has a flake size of only about 1–2 μm. Additional peaks, corresponding to CuO, can be seen at 2θ > 25° after
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onal network of graphene. As a result, the actual sp2 carbon

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region. This is indicative of the presence of large amount of

defect sites due to the attachment of metal oxide nano-

particles on the HEG basal sheet.

decoration with copper oxide, which suggests an intense crys-
tallinity of NPs. The crystal structure of CuO is monoclinic, and
the crystallite size calculated using the Scherrer equation is

~18 nm.

Fig. 1b shows the measured Raman spectra of CuO/f-HEG and f-HEG (the Raman spectrum of f-HEG is described else-

where). In brief, f-HEG exhibits a Raman spectrum similar to

that of graphite oxide with broad D and G bands and a flat 2D region. This is indicative of the presence of large amount of
defects as well as functional groups, which disturb the hexag-

onal network of graphene. As a result, the actual sp2 carbon
domain size is small, leading to the suppression of the 2D band.

Upon metal oxide loading, small shifts and broadening are

observed in the D and G bands. This shift in CuO/f-HEG arises

from the interaction of metal oxide nanoparticles with f-HEG sheets. It can also be seen that the peak intensity ratio of the D and G bands (I_D/I_G) decreases from 1.12 ± 0.03 (f-HEG) to 0.95 ± 0.02 (CuO/f-HEG). Such a reduction, which has been observed in other metal oxide–nanocarbon composites as well, is attributed to the reduction in the number of dangling bonds or other
defect sites due to the attachment of metal oxide nanoparticles. Fig. 1c is the TEM image of the CuO/f-HEG hybrid, which clearly shows the uniform decoration of the HEG sheet by CuO nanoparticles. The metal oxide loading is maintained at 20 wt%, which is confirmed by weighing the samples before and after loading.

3.2. Optical limiting in CuO/f-HEG hybrids

CuO/f-HEG exhibited excellent optical nonlinearity when

excited by ns as well as fs laser pulses. The open aperture Z-scan curves of the samples plotted between the sample position and

normalized transmittance, in both ns and fs excitation regimes, are shown in Fig. 2a and b, respectively. It is evident that light transmission decreases with an increase in the input light intensity (which is highest at the beam focus, z = 0, and decreases uniformly in either direction), indicating a nonlinear response in both the excitation regimes. The semi-transparent nature of CuO/f-HEGs (linear transmittance of 70%) and the nonlinear transmission characteristics shown in Fig. 2a and b suggest that CuO/f-HEG is an efficient optical limiter for short-pulse as well as ultrafast laser pulses.

In general, a good optical limiter relies on one or more of the NLO processes such as NLA, nonlinear refraction, and induced thermal scattering (ITS) for efficient light attenuation at high intensities. The smooth valley shaped Z-scan curves shown in Fig. 2a and b, which are symmetric about the focal point, suggest the relative predominance of NLA. Depending on the material under study, excitation wavelength and pulse width, NLA can occur via mechanisms such as multiphoton absorption and/or excited state absorption (ESA). Numerical simulations reveal that the best fit to the present Z-scan data is obtained when a two-photon absorption (2PA) process is considered for both excitation regimes. The transmission of a two-photon absorber is given by

\[
T = \left[ \left( 1 - R \right)^2 \exp\left( -\alpha_o L \right) / \sqrt{\pi q_o} \right] \int_0^\infty \ln \left[ 1 + q_o \exp\left( -r^2 \right) \right] dr
\]

(1)

where L and R are the sample length and surface reflectivity, respectively. \( \alpha_o \) is the linear absorption coefficient and \( q_o \) is given by \( \beta \left( 1 - R \right) L_e f \), where \( \beta \) is the 2PA coefficient. The effective length, \( L_{eff} \), is given by \( \left( 1 - \exp\left( -\alpha_o L \right) / \alpha_o \right). The
obtained $\beta$ values are of the order of $10^{-10}$ m W$^{-1}$ in the ns regime and $10^{-14}$ m W$^{-1}$ in the fs regime. However, a good numerical fit of the experimental data to eqn (1) does not necessarily indicate the exclusive occurrence of 2PA; moreover, the nonlinearity may have contributions from two-step ESA.$^{16}$ In fact, by making a number of $Z$-scan measurements at different laser pulse energies and plotting the 2PA coefficients ($\beta$) against the corresponding on-axis peak intensities, the true underlying mechanisms of the observed nonlinearity can be elucidated. For instance, the cross section of a genuine two-photon process is too low to deplete the ground state population appreciably, and therefore, for a given excitation wavelength and sample concentration, the variation of $\beta$ with on-axis peak intensity is negligible. On the other hand, ESA can cause substantial transient depletion of the ground state with pulsed excitation, with the result that $\beta$ varies with on-axis peak intensity.$^{17}$ Our measurements reveal that $\beta$ indeed varies (decreases) with on-axis peak intensity, as shown in Fig. 3a and b, for fs and ns excitation, respectively, indicating the occurrence of ESA in both the excitation regimes. Even in the case of Pd/f-HEG and Pt/f-HEG hybrids, NLA coefficients were found to be dependent on on-axis peak intensity, wherein $\beta$ values increase with $I_o.$ It is important to note that ESA can lead to either an increase or decrease in the $\beta$ values, as a function of $I_o$, depending on the absorption cross-sections of the ground state and the excited state, and the excited state lifetimes. Therefore, the trend can vary from one material to another.

The optical limiting threshold (LT), defined as the input fluence at which the transmittance falls to half the linear transmittance value, can be used for a quantitative comparison of the OL performance of different materials. From the definition, it follows that the lower the LT value, the better the limiting performance. Since LT is dependent on sample linear transmittance, laser pulse width, and excitation wavelength, comparison of the LT values of different optical limiters becomes meaningful only if the measurements are performed under similar experimental conditions. In the case of open aperture $Z$-scan using a Gaussian beam, the input fluence at each $z$-position is given by $F(z) = 4\sqrt{\ln 2} \frac{E_{in}}{\pi} \frac{w(z)^2}{w(z)^2}$, where $E_{in}$ is the input laser pulse energy and $w(z)$ is the beam radius. A plot of $F(z)$ vs. transmittance yields the optical limiting curve (Fig. 4a and b), from which the LT values can be found. The values measured in CuO/f-HEG for ns and fs excitations are 4.35 J cm$^{-2}$ and 1.43 J cm$^{-2}$, respectively. On the other hand, the LT value obtained in f-HEG in the fs excitation regime is 2.7 J cm$^{-2}$, while limiting is not strong enough to estimate LT values in the ns excitation regime. Thus, it is clear that CuO decoration has significantly improved the OL performance of f-HEG in both the excitation regimes. It may be noted that the fs limiting threshold values of the CuO/f-HEG hybrids are better than those of previously reported benchmark materials like C$_{60}$ (~2 J cm$^{-2}$)$^{16}$ carbon black (~2.2 J cm$^{-2}$)$^{16}$ and f-HEG decorated with metal NPs like Ag (~1.9 J cm$^{-2}$)$^{7}$ Pd (~1.8 J cm$^{-2}$)$^{16}$ and Pt (~1.5 J cm$^{-2}$)$^{16}$, making CuO/f-HEG attractive for applications such as eye and sensor protection from hazardous laser radiation. In addition, the $\beta$ values of CuO/f-HEG hybrids in the ns excitation regime are higher than that of other composite systems such as ZnO/reduced graphene oxide$^8$ and CdS/graphene.$^9$ Such superior nonlinear behavior is also highly promising for building

**Fig. 2** Open aperture $Z$-scan curves measured for f-HEG, CuO NP and CuO/f-HEG with (a) 5 ns pulses at 532 nm, and (b) 100 fs pulses at 800 nm. Solid lines are theoretical fits to the $Z$-scan data. For comparison, the best fit obtained with a three-photon absorption (3PA) equation in the case of CuO NPs is given. It is clear that the 2PA fit is significantly better than the 3PA fit.

**Fig. 3** Variation of 2PA coefficient with on-axis peak intensity ($I_o$) in the (a) fs excitation regime and (b) ns excitation regime, indicating the occurrence of two-step ESA in both the cases.
photonic logic devices such as all-carbon optical diode based on axial asymmetry in nonlinearity.20

Graphene possesses outstanding nonlinear absorption properties by virtue of its unique electronic band structure. Energy dispersion is linear in the vicinity of the K point,21 which allows for the coupling of any level in the valence band to any desired level in the conduction band by a photon of appropriate energy, enabling wideband tunability. As mentioned before, epitaxial graphene and CVD grown graphene are known to be excellent saturable absorbers. When photoexcited, a non-equilibrium carrier population is formed in the valence band and conduction band of graphene. Once a steady state is reached between the excited electrons and electrons relaxing to initial states, further absorption of photons within the pulse width is restricted due to Pauli blocking.22 The increased light transmission thus achieved at higher intensities finds applications in mode-locking,23 pulse shaping and optical switching.24 On the other hand, HEG shows strong optical limiting due to the large number of defect induced states, which enhances NLA, causing attenuation of laser intensity at higher incident fluences.25 The mechanism of NLA was found to be ESA in the ns regime, and 2PA combined with saturable absorption (2PA + SA) in the fs regime.26 Although HEG contains remnant oxygen functionalities (~6–8 wt%) even after reduction from GO, they are not sufficient to sustain stable dispersions. But, many of the practical applications, including optical limiters and nanofluids, require long-term stable dispersions.27 The acid functionalization of HEG to form f-HEG increases its solubility in solvents, which also helps in the uniformity of metal oxide loading. We have shown previously that increasing defects through acid functionalization is a facile method for improving the OL properties of HEG.28 Furthermore, the features of the UV-Vis spectrum of f-HEG and the increase in the I$_{2s}$/I$_{2p}$ ratio (0.88 to 1.12) confirm the increase in the defect density. The mechanism of NLA in f-HEG remains the same as that in HEG.

The observed enhancement in the LT values of MO/f-HEG can be primarily attributed to NLA in the CuO NPs. NLA in CuO NPs can be linked to the presence of surface states, as discussed below. Photoluminescence studies carried out by El-Trass et. al. have revealed the presence of surface states in CuO NPs arising due to oxygen vacancies and Cu interstitials.29 Previously, we have shown that NLA in ZnO nanotetrapods is strongly influenced by the surface states induced by Zn interstitials.30 In a similar fashion, the large surface state density could lead to strong NLA in CuO NPs as well. The reported band gap for CuO NPs of 5–10 nm size is ~2.1 eV,27 and therefore ns excitation at 532 nm (2.33 eV) will result in interband transitions between the d band and s–p conduction band. Subsequent ESA to higher lying states in the conduction band results in NLA, as shown in Fig. 2. Absorption at 800 nm (1.55 eV) can be attributed to the d–d transitions in the partially filled 3d$^9$ state of the dispersed Cu$^{2+}$ species.31 Furthermore, in a recent study, Rao and co-workers have shown that when graphene is decorated with metal NPs, charge transfer takes place at the graphene–metal interface to achieve a common Fermi level.32 Charge transfer is from graphene to metal in the case of Ag, Pd and Pt NPs, while for Au NPs, it is from metal to graphene. Recently, similar observations have been made in the case of metal oxides like ZnO and MoO$_3$.28,33 Since the work functions of CuO and f-HEG are 5.2 eV34 and 4.5 eV,35 respectively, charge transfer from f-HEG to CuO NPs is possible in the present case. The transferred excited carriers from f-HEG undergo subsequent ESA transitions in the large density of metal oxide states, leading to an overall increase in NLA in the composite system, which in turn results in an improved OL performance.

### 3.3. Carrier dynamics in f-HEG and CuO/f-HEG

The ultrafast differential transmission spectra ($\Delta T (t)/T$) of f-HEG and CuO/f-HEG measured from degenerate pump–probe measurements are given in Fig. 5. Here, $T$ is the probe transmission in the absence of pump beam, and $\Delta T(t)$ is the change in probe transmission at time $t$ after excitation by the pump. The differential transmission data is fitted with a tri-exponentially decaying function $\Delta T/T = A_1 \exp(-t/\tau_1) + A_2 \exp(-t/\tau_2) + A_3 \exp(-t/\tau_3)$, as shown in Fig. 5. The three distinct decay time constants obtained from the best fits provide information regarding various relaxation mechanisms. In the case of f-HEG (see Fig. 5a), the fast component $\tau_1$ (210 fs) can be attributed to interband carrier–carrier scattering, while the slow component $\tau_2$ (1.5 ps) arises from carrier–phonon scattering.32,33 The third component $\tau_3$ of the time decaying function is much slower (35 ps), and can be associated with carrier trapping by defect states, which arises from oxygen functionalities and other structural
defects.\textsuperscript{32} Such trap states are found to play a major role in prolonging carrier relaxation in reduced graphene oxide to the range of 30–400 ps.\textsuperscript{34} As mentioned before, the strong OL in HEG and \textit{f}-HEG arises mainly due to the ESA mediated by these defect induced states.\textsuperscript{4}

In general, carrier dynamics in graphene and reduced graphene oxide can be described as follows. Intraband and interband one-photon and two-photon absorption processes during photo-excitation lead to a narrow non-equilibrium carrier distribution in the valence and conduction bands of graphene.\textsuperscript{35} The carriers quickly equilibrate in a timescale of 10–200 fs via inelastic and elastic intraband carrier–carrier scattering to reach a hot Fermi–Dirac distribution.\textsuperscript{36} Subsequently, these hot electrons cool down in a timescale of 1–2 ps by interband carrier–phonon scattering involving both optical and acoustic phonons, reaching thermal equilibrium with the lattice.\textsuperscript{37} In the case of carrier trapping by trap states, carrier relaxation to the ground state gets delayed by hundreds of ps, up to a few ns.\textsuperscript{34,36} An important factor determining carrier dynamics in graphene is the defect density. Ultrafast time resolved measurements carried out in epitaxial graphene by Dawlaty \textit{et al.} reveal that carrier relaxation times decrease with an increase in defects (\textit{i.e.}, increase in the $I_{2D}/I_C$ ratio) in the graphene lattice that reduces the in-plane crystallite size.\textsuperscript{38} As mentioned before, the $I_{2D}/I_C$ ratio of \textit{f}-HEG reduces from 1.12 ± 0.03 to 0.95 ± 0.02 upon metal oxide loading, because the CuO NPs attach to the dangling bonds at the edges of \textit{f}-HEG sheets.\textsuperscript{14} Therefore, the reduction in $\tau_1$ and $\tau_2$ values observed with CuO/\textit{f}-HEG is not due to the effect of defects, but due to the higher carrier density in CuO/\textit{f}-HEG compared to \textit{f}-HEG.\textsuperscript{32} The increase in $\tau_3$ can be associated with the longer lived trap states in CuO nanoparticles, which further delay carrier relaxation.\textsuperscript{37}

### 3.4. Contribution of induced thermal scattering towards optical limiting

Many of the previously reported NLO studies on graphene based nanocarbon suspensions have revealed that induced thermal scattering (ITS) is the predominant mechanism contributing to observed OL.\textsuperscript{26,29} When excited with intense laser pulses, graphene flakes get heated up and transfer the heat energy to the surrounding solvent. This localized heating leads to the formation of solvent bubbles, which expand quickly due to the large pressure difference at the vapor–solution interface. When the size of the solvent bubbles becomes comparable to the excitation wavelength, they reduce the light transmission considerably due to Mie scattering. Alternatively, the intense photon flux can ionize the graphene flakes directly, forming rapidly expanding micro-plasma, which also acts as scattering centers.\textsuperscript{39,40} In general, scattering centers take several nanoseconds for their formation. Therefore, the effect of ITS is significant only in ns or longer pulse excitation regimes.

In order to study the contribution of ITS towards the OL performance of CuO/\textit{f}-HEG, we measured the variation of light scattering from the dispersion during a ns $Z$-scan run with an on-axis peak intensity of 4.77 GW cm$^{-2}$. A photodiode kept close to the sample at an angle of 45° to the beam axis was used for the measurements. The measured scattering signal is plotted in Fig. 6. The variation in signal amplitude, which is from 0.18 to 0.26 V, is not significant enough to contribute substantially to the observed optical limiting. This suggests a weak ITS compared to NLA in the present case. This is also indirectly evident from the fact that the 2PA equation fits to the $Z$-scan data very well. In fact, the laser beam transmitted through the sample maintains the same transverse profile visibly, indicating negligible distortions due to scattering. Previous studies carried out on \textit{f}-HEG and metal/\textit{f}-HEG hybrids also showed negligible contribution of ITS towards OL.\textsuperscript{4,7} This is mainly due to the fact that, compared to the earlier studies carried out on graphene suspensions containing isolated particles, here we have used stable dispersions of high thermal conductivity, which act as thermally homogenous media with better thermal diffusion. In fact, the thermal conductivity and heat transfer coefficient of CuO/\textit{f}-HEG are higher than those of \textit{f}-HEG.\textsuperscript{3} As a result, heat
generated locally by ns excitation will be dissipated evenly to the surroundings easily, thereby reducing the formation of localized scattering centers. Moreover, the measurements were carried out in the single-shot mode such that only one laser pulse was incident on the sample in every 2 seconds: in this way, chances of accumulative thermal effects were minimized. Therefore, the observed OL in CuO/f-HEG primarily occurs from strong NLA in both the ultrafast and short-pulse excitation regimes.

4. Conclusions

In conclusion, nonlinear optical properties of CuO/f-HEG hybrids have been studied using the open aperture Z-scan technique in both ultrafast (fs) and short-pulse (ns) laser excitation regimes. The excellent optical limiting response measured in CuO/f-HEG is attributed to (a) strong nonlinear absorption in HEG mediated by defect induced states, which increase in number by acid functionalization, (b) nonlinear absorption in CuO nanoparticles due to excited state absorption, and (c) charge transfer between f-HEG and CuO nanoparticles. Ultrafast carrier dynamics measurements confirm the role of defect induced states, which prolong the relaxation dynamics by carrier trapping. The contribution of induced thermal scattering towards the observed optical limiting is negligible due to the fine dispersibility of the samples in water, combined with their excellent thermal transport properties. The present study reveals that metal oxide decoration is an effective method for making excellent optical limiters using hydrogen exfoliated graphene.

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